

# In-beam Analogue Pixel Test Structure characterization

Giacomo Alocco (University & INFN Cagliari)  
on behalf of the ALICE collaboration

11th Beam Telescopes and Test Beams Workshop

20/04/2023



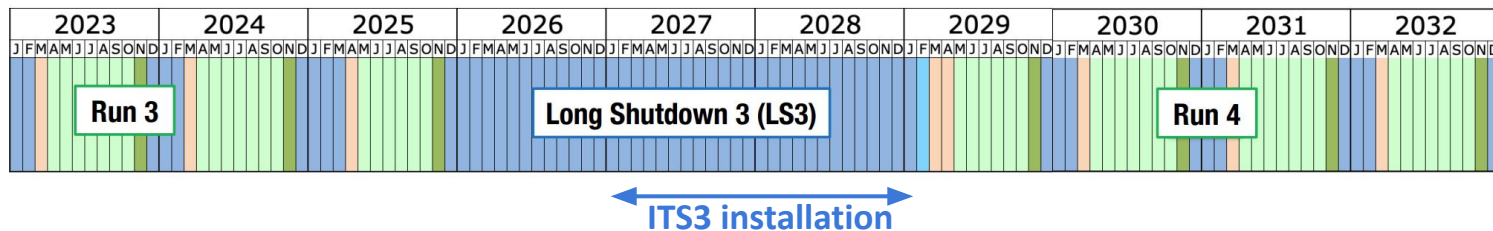
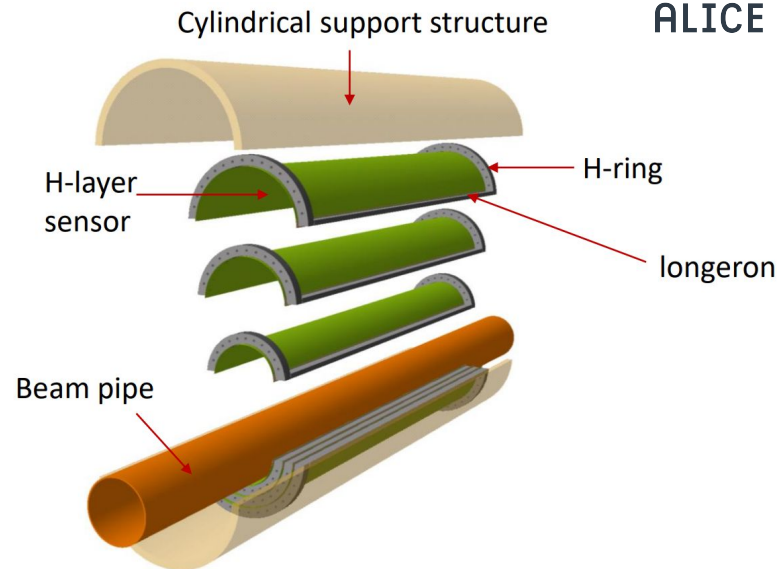
**ALICE**



Istituto Nazionale di Fisica Nucleare

# ALICE ITS upgrade

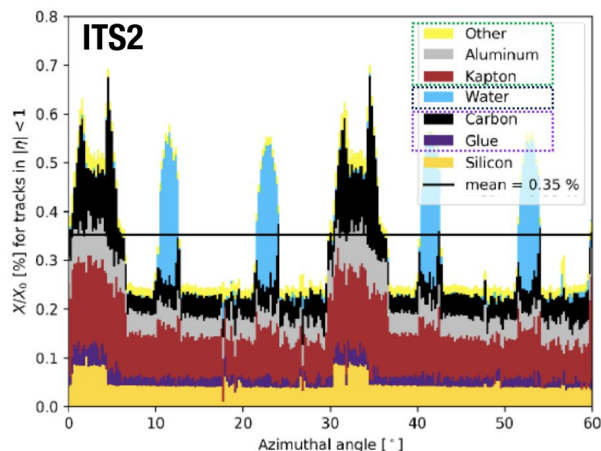
- The 3 innermost layers of the current ALICE inner tracking system (ITS2) will be replaced with the a new detector (ITS3)
- Wafer scale detector (up to 280 x 94 cm<sup>2</sup>): stitching will be used
- ITS3 will feature:
  - Bent detectors
  - Innermost layer closer to the interaction point: 18 mm vs 23 mm (ITS2)
  - Less material budget: 0.05%  $X_0$  vs 0.35%  $X_0$  of the current detector (ALPIDE)



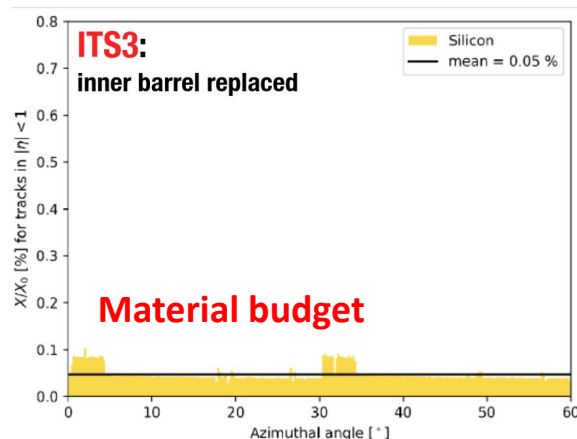
# ALICE ITS upgrade



- ITS3 will have a lower material budget:
  - Circuit board: **not required** if integrated in circuit
  - Water cooling: **not required** if power consumption < 20 mW/cm<sup>2</sup>
  - Mechanical support: **not required** if self supporting arched structure



x 1/7



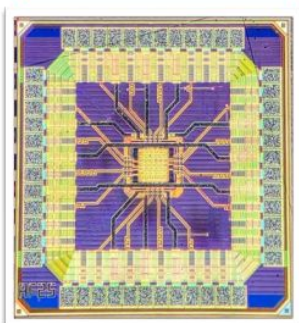
- The new ITS3 detector will improve both the tracking resolution and the tracking efficiency w.r.t the current ITS2 at low  $p_T$

# Chip prototypes

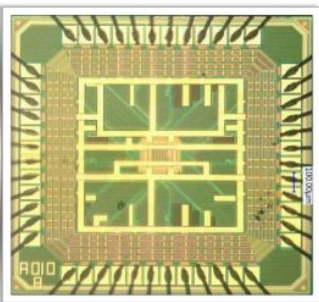
- The target technology for these new detectors is the 65 nm CMOS imaging process by Tower Partners Semiconductor Co.
- Chip prototypes developed in collaboration with CERN EP R&D
- 4 prototypes of chips are available:



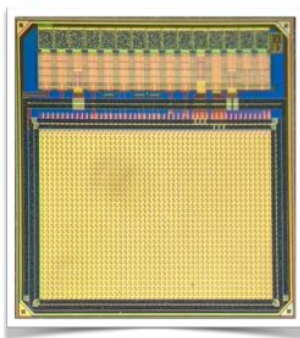
APTS SF



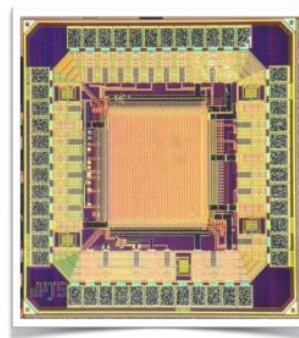
APTS OA



CE65



DPTS



- 4 x 4 pixel matrix
- Analogue readout of all 16 pixels
- 10, 15, 20, 25  $\mu\text{m}$  pitch
- Two versions of output buffer:
  - Operational Amplifier (OA) can directly drive  $50\Omega$  to allow faster readout

- 64 x 32 pixel matrix
- 15  $\mu\text{m}$  pitch
- 3 pixel architectures

- 32 x 32 pixel matrix
- 15  $\mu\text{m}$  pitch
- Asynchronous digital readout
- Time encoded pixel position
- ToT measurements

# Chip prototypes

- The target technology for these new detectors is the 65 nm CMOS imaging process by Tower Partners Semiconductor Co.
- Chip prototypes developed in collaboration with CERN EP R&D
- 4 prototypes of chips are available:

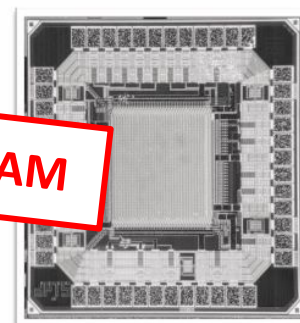
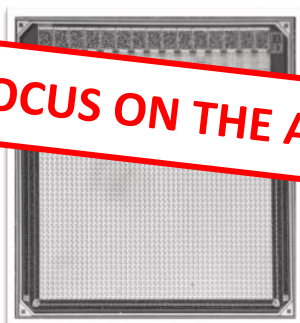
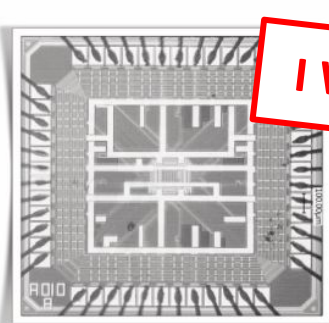
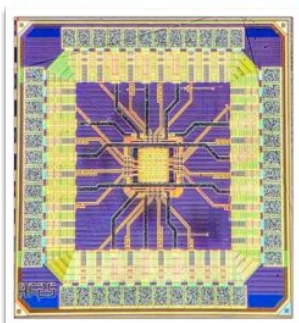


APTS SF

APTS OA

CE65

DPTS



**I WILL FOCUS ON THE APTS-SF TEST BEAM**

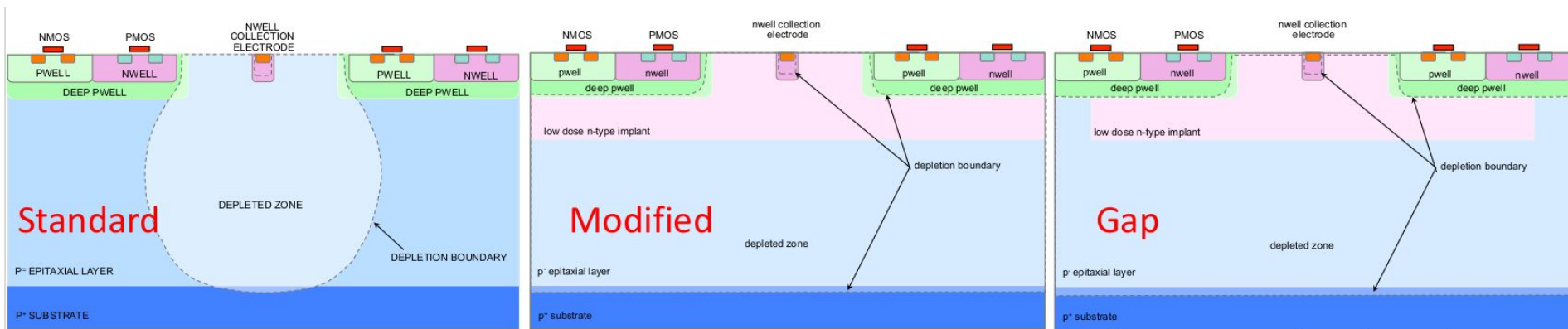
- 4 x 4 pixel matrix
- Analogue readout of all 16 pixels
- 10, 15, 20, 25  $\mu\text{m}$  pitch
- Two versions of output buffer:
  - Operational Amplifier (OA) can directly drive 50 $\Omega$  to allow faster readout

- 64 x 32 pixel matrix
- 15  $\mu\text{m}$  pitch
- 3 pixel architectures

- 32 x 32 pixel matrix
- 15  $\mu\text{m}$  pitch
- Asynchronous digital readout
- Time encoded pixel position
- ToT measurements

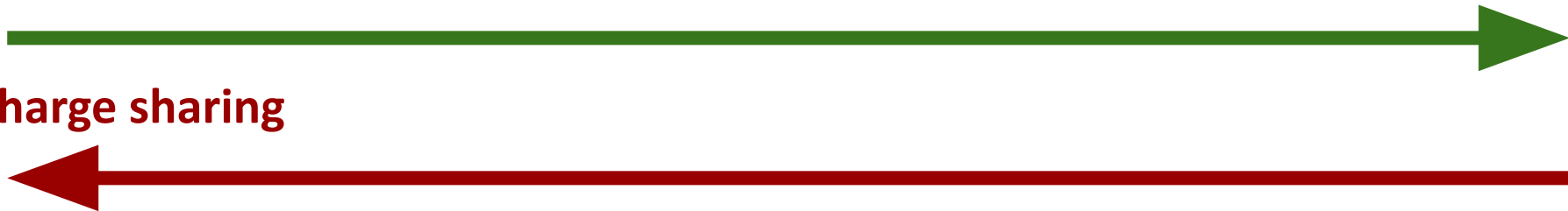
# Process modification

- The APTS-SF are available with three different types
- The types differs in how the charges left by ionizing particles going through the detectors move



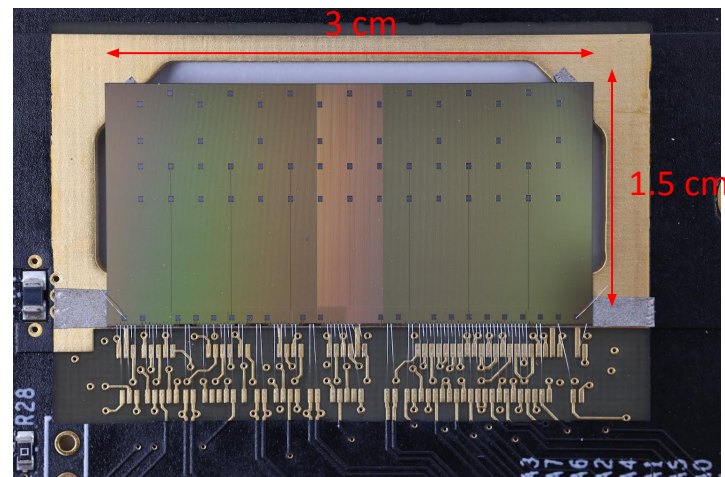
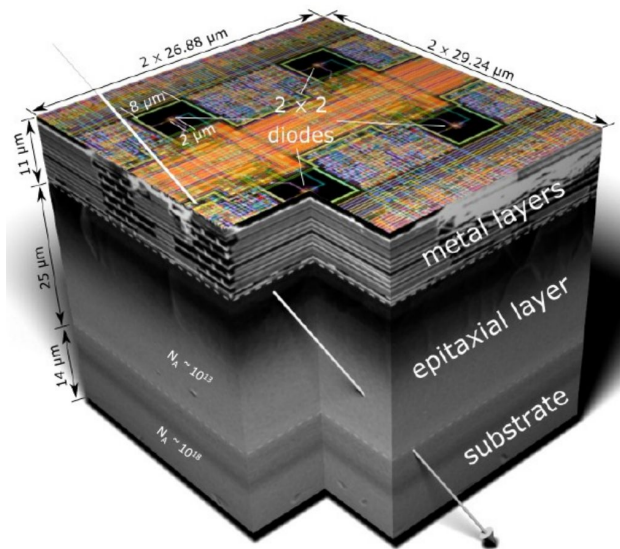
Charge collection efficiency and speed

Charge sharing



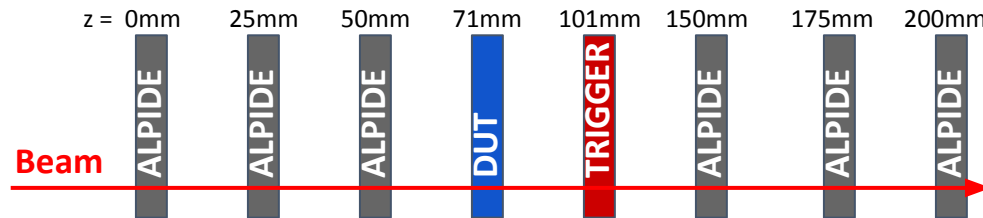
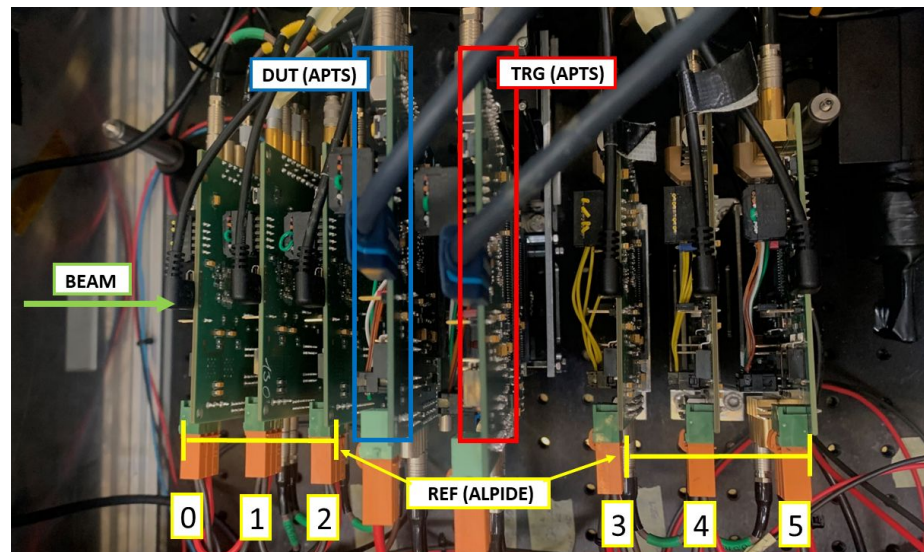
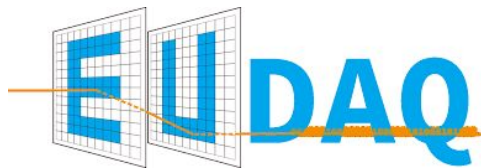
# The ALPIDE telescope

- Beam test telescope based on the ALPIDE chip
  - MAPS detector on 180 nm CMOS technology
  - $1024 \times 512$  pixels,  $29 \mu\text{m} \times 27 \mu\text{m}$  pixel pitch
  - Low material budget:  $50 \mu\text{m}$  of silicon per plane ( $0.05\% X_0$ )
  - $5 \mu\text{m}$  spatial resolution
  - Detection efficiency above 99%



# Testbeam setup - PS August 22

- Data taken in August 2022 using hadrons extracted from the CERN Proton Synchrotron (PS) with a momentum of 12 GeV/c
- A telescope was built using:
  - 6 ALPIDEs
  - Trigger given by an APTS-SF with a pixel pitch of 25  $\mu\text{m}$
  - 1 APTS-SF: device under test (DUT) mounted on a moving stage
- ALPIDE planes and DUT are controlled and data acquired by using EUDAQ2:
  - <https://github.com/eudaq/eudaq>

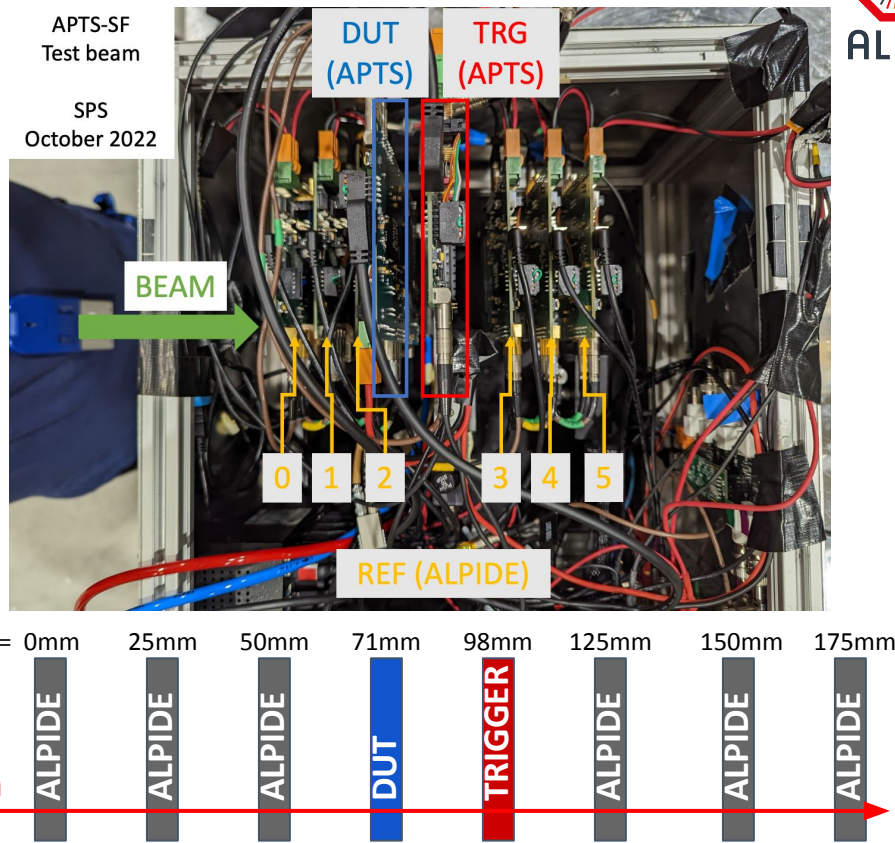


- Tracking resolution  $\sigma_{\text{Trk}} = 4 \mu\text{m}$  at  $z = z_{\text{DUT}}$



# Testbeam setup - SPS October 22

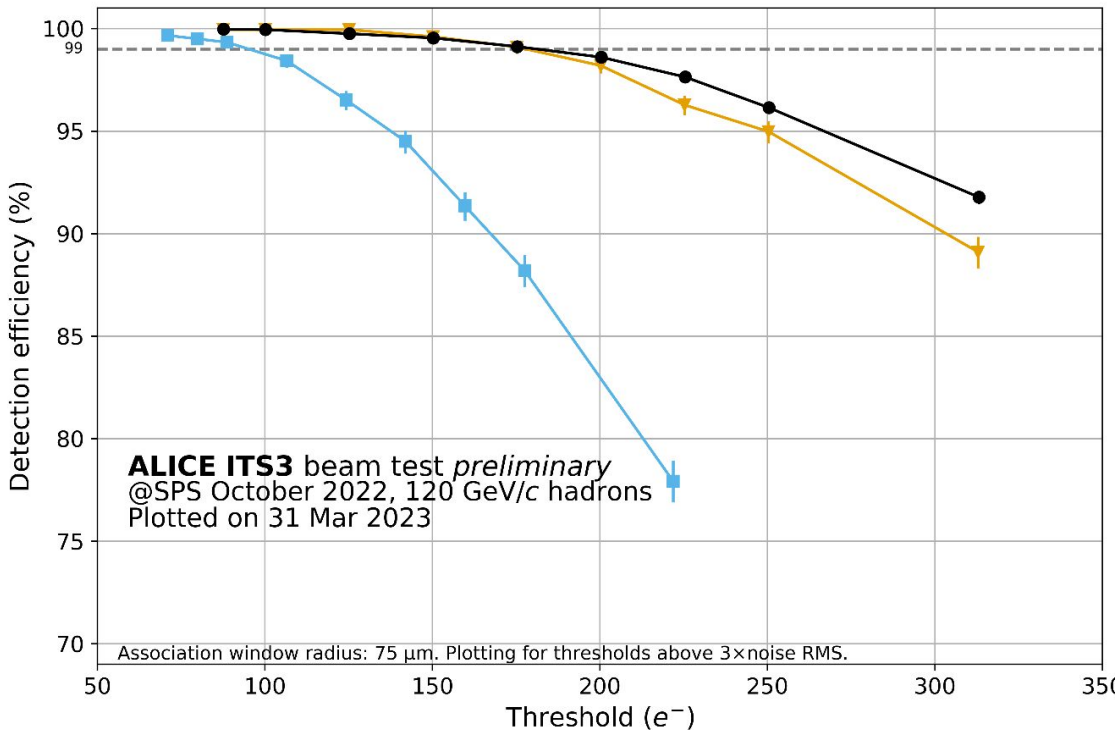
- Data taken in October 2022 using hadrons extracted from the CERN Super Proton Synchrotron (SPS) with a momentum of 120 GeV/c
- A telescope was built using:
  - 6 ALPIDEs
  - Trigger given by an APTS-SF with a pixel pitch of 25  $\mu\text{m}$
  - 1 APTS-SF: device under test (DUT) mounted on a moving stage
- Tracking resolution  $\sigma_{\text{Trk}} = 2.1 \mu\text{m}$  at  $z = z_{\text{DUT}}$



# Efficiency vs threshold: type comparison for pitch = 15 $\mu\text{m}$



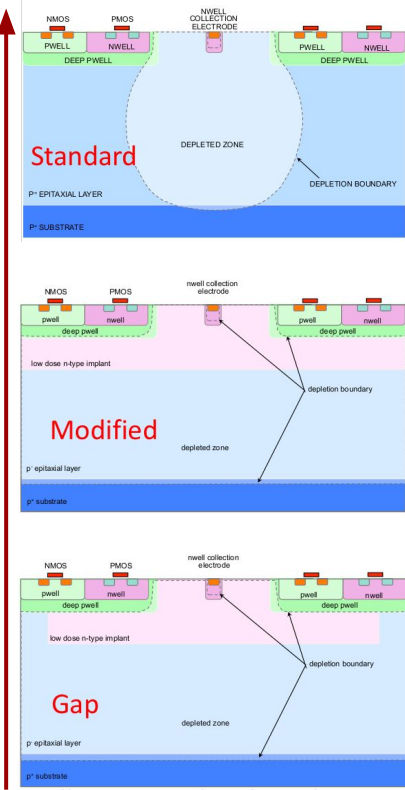
- Analysis is conducted with Corryvreckan:
  - <https://gitlab.cern.ch/corryvreckan/corryvreckan>
- Data plotted for threshold > 3RMS<sub>noise</sub>
- Larger operational margin for the modified with gap and modified type



**APTS SF**  
 Non-irradiated  
 pitch: 15  $\mu\text{m}$   
 split: 4  
 $I_{reset} = 100 \text{ pA}$   
 $I_{biasn} = 5 \text{ }\mu\text{A}$   
 $I_{biasp} = 0.5 \text{ }\mu\text{A}$   
 $I_{bias4} = 150 \text{ }\mu\text{A}$   
 $I_{bias3} = 200 \text{ }\mu\text{A}$   
 $V_{reset} = 500 \text{ mV}$   
 $V_{pwell} = V_{sub} = -1.2 \text{ V}$   
 $T = 20 \text{ }^\circ\text{C}$

- Standard
- ✦ Modified
- Modified with gap

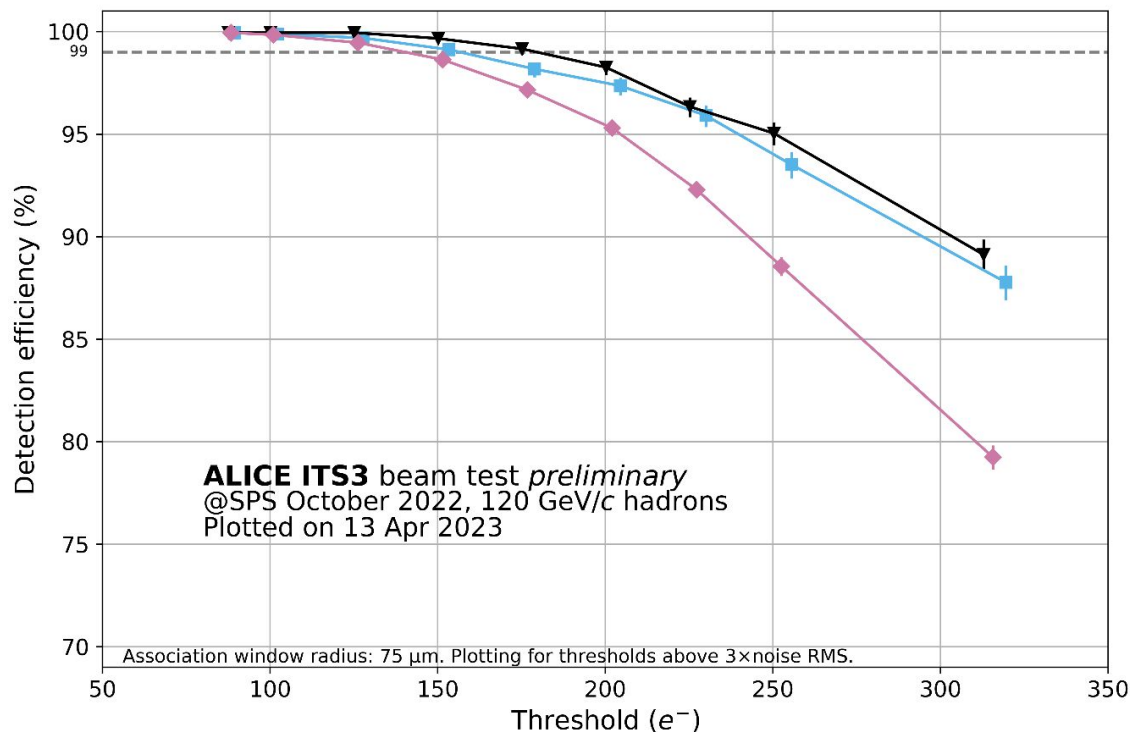
Charge sharing



Charge collection efficiency and speed

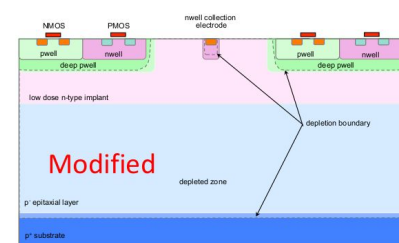
# Efficiency vs threshold: modified type pitch comparison

- Data plotted for threshold  $> 3\text{RMS}_{\text{noise}}$
- The modified type is available with pitch of 10, 15 and 25  $\mu\text{m}$
- Larger operational margin for the smaller pitches



## APTS SF

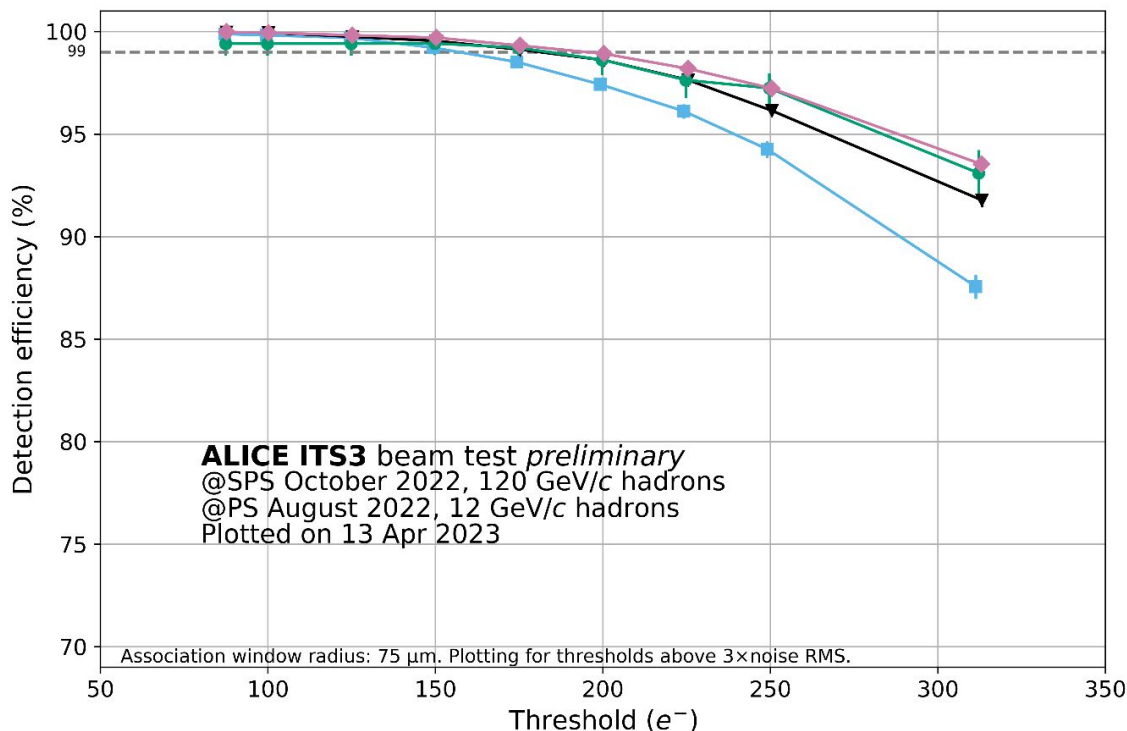
Non-irradiated  
type: modified  
split: 4  
 $I_{\text{reset}} = 100 \mu\text{A}$   
 $I_{\text{biasn}} = 5 \mu\text{A}$   
 $I_{\text{biasp}} = 0.5 \mu\text{A}$   
 $I_{\text{bias4}} = 150 \mu\text{A}$   
 $I_{\text{bias3}} = 200 \mu\text{A}$   
 $V_{\text{reset}} = 500 \text{mV}$   
 $V_{\text{pwell}} = V_{\text{sub}} = -1.2 \text{V}$   
 $T = 20 \text{ }^\circ\text{C}$



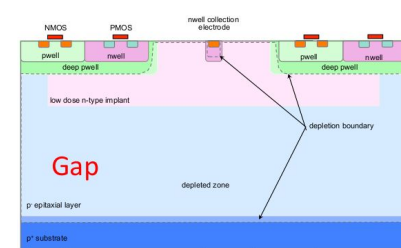
- Pitch = 10  $\mu\text{m}$
- Pitch = 15  $\mu\text{m}$
- Pitch = 25  $\mu\text{m}$

# Efficiency vs threshold: gap type pitch comparison

- Data plotted for threshold  $> 3RMS_{noise}$
- The modified with gap type is available with pitch of 10, 15, 20, and 25  $\mu m$
- Different trend w.r.t. the modified:
  - Larger operational margin going to larger pitches



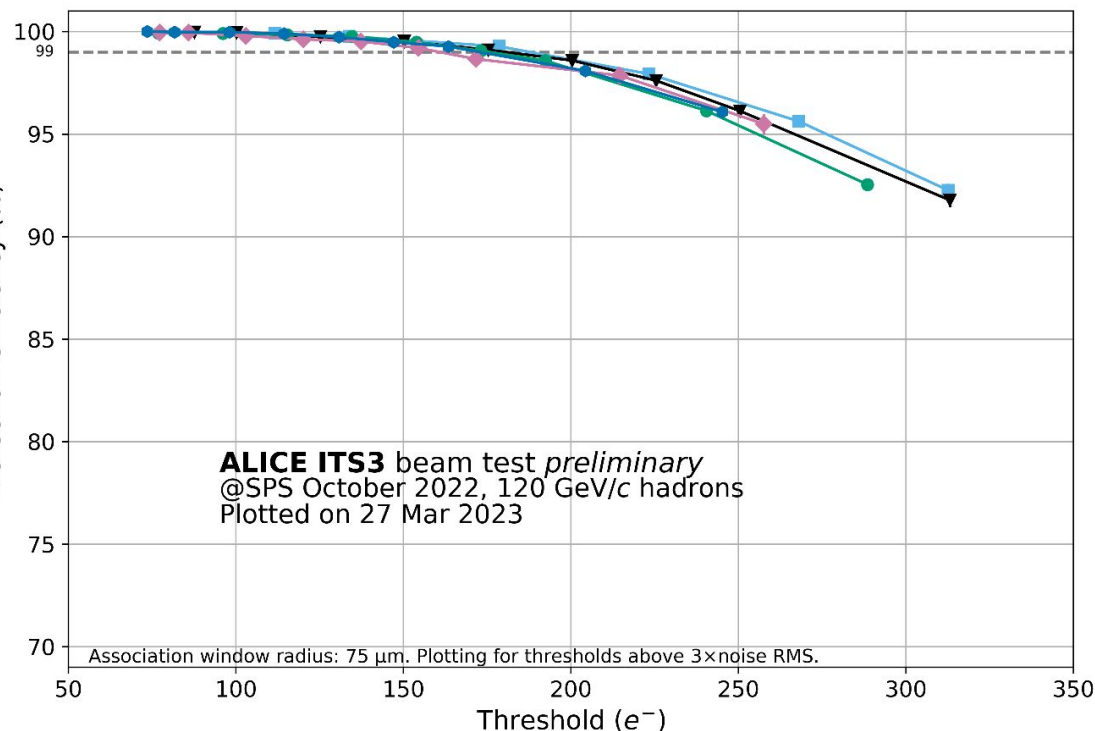
**APTS SF**  
 Non-irradiated  
 type: modified with gap  
 split: 4  
 $I_{reset} = 100 \mu A$   
 $I_{biasn} = 5 \mu A$   
 $I_{biasp} = 0.5 \mu A$   
 $I_{bias4} = 150 \mu A$   
 $I_{bias3} = 200 \mu A$   
 $V_{reset} = 500 mV$   
 $V_{pwell} = V_{sub} = -1.2 V$   
 $T = 20 \text{ } ^\circ C$



- ◆ Pitch = 10  $\mu m$
- ◆ Pitch = 15  $\mu m$
- ◆ Pitch = 20  $\mu m$
- ◆ Pitch = 25  $\mu m$

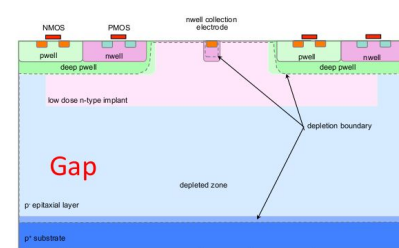
# Efficiency vs threshold: gap type bias comparison

- Data plotted for threshold  $> 3\text{RMS}_{\text{noise}}$
- No effect of the  $V_{bb}$  in the efficiency for the pitch =  $15\mu\text{m}$ :
  - True also for the modified type but not for the standard type (check the backup)



## APTS SF

Non-irradiated  
type: modified with gap  
pitch:  $15\mu\text{m}$   
split: 4  
 $I_{reset} = 100\text{ pA}$   
 $I_{bias1} = 5\mu\text{A}$   
 $I_{bias2} = 0.5\mu\text{A}$   
 $I_{bias3} = 150\mu\text{A}$   
 $I_{bias4} = 200\mu\text{A}$   
 $V_{reset} = 500\text{ mV}$   
 $V_{pwell} = V_{sub}$   
 $T = 20\text{ }^\circ\text{C}$



- ◆  $V_{sub} = 0.0\text{ V}$
- ◆  $V_{sub} = -1.2\text{ V}$
- ◆  $V_{sub} = -2.4\text{ V}$
- ◆  $V_{sub} = -3.6\text{ V}$
- ◆  $V_{sub} = -4.8\text{ V}$

# Summary



- APTS is a MAPS fabricated in 65 nm CMOS imaging sensor technology
- Chip thoroughly tested during several testbeam campaigns. Data taken for:
  - Standard type:
    - 15 $\mu$  pitch with  $V_{bb}$  scan
  - Modified type:
    - 10, 15, and 25  $\mu$ m pitch with  $V_{bb}$  scan
  - Modified with gap type:
    - 10, 15, 20, and 25  $\mu$ m pitch with  $V_{bb}$  scan
    - 15  $\mu$ m pitch with  $V_{bb}$  scan of irradiated chips:  $10^{15}$ ,  $2 \cdot 10^{15}$  1MeV  $n_{eq}$  cm<sup>-2</sup>
- Non-irradiated device under standard operation conditions:
  - Modified with gap and modified have larger operational margin than the standard type
  - Different operational margin for different pitches:
    - Modified: higher for smaller pitches
    - Modified with gap: higher for larger pitches
  - No dependence on the  $V_{bb}$  for the modified and modified with gap type

# Outlook



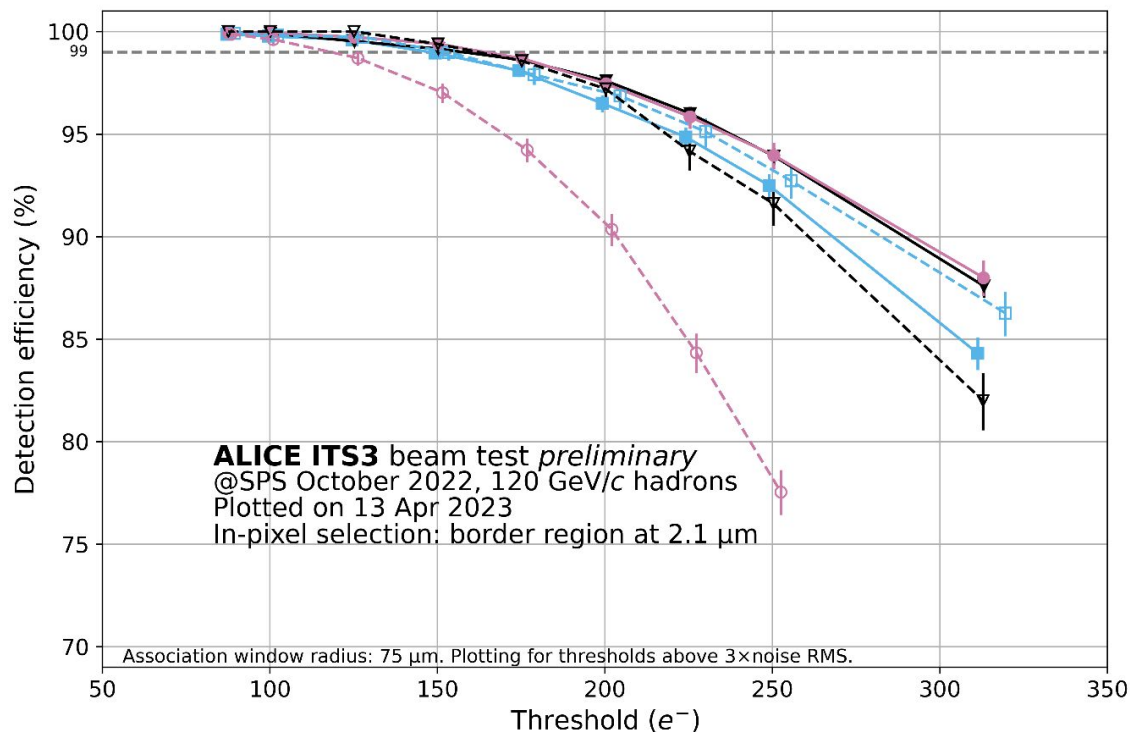
- Analysis of the spatial resolution analysis completed:
  - Ongoing discussion on with clusterization method to apply
- In-pixel efficiency studies:
  - Precise measurement of effect of the low dose n-type implants (w/o gap)
- New test beam planned at the CERN PS in May:
  - To study more irradiation levels,  $V_{bb}$  values
  - High statistics run data taking for in-pixel studies

**Backup**



# Efficiency vs threshold: pitch comparison

- Measuring the efficiency in the border region of the pixels:
  - The modified with gap show similar trend
  - For the modified it still depend on the pixel pitch



## APTS SF

Non-irradiated  
split: 4

$I_{reset} = 100 \text{ pA}$

$I_{biasn} = 5 \text{ }\mu\text{A}$

$I_{biasp} = 0.5 \text{ }\mu\text{A}$

$I_{bias4} = 150 \text{ }\mu\text{A}$

$I_{bias3} = 200 \text{ }\mu\text{A}$

$V_{reset} = 500 \text{ mV}$

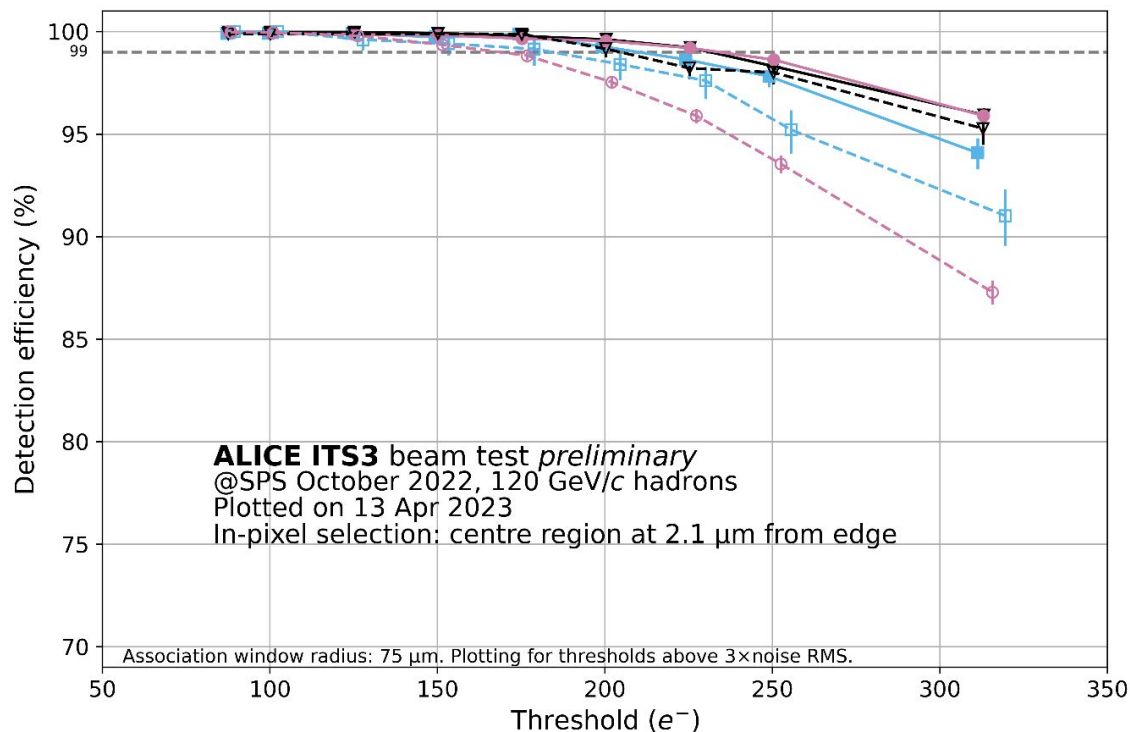
$V_{pwell} = V_{sub} = -1.2 \text{ V}$

$T = 20 \text{ }^\circ\text{C}$

- Modified with gap
- Modified
- Pitch = 10  $\mu\text{m}$
- ▲— Pitch = 15  $\mu\text{m}$
- ◆— Pitch = 25  $\mu\text{m}$

# Efficiency vs threshold: pitch comparison

- Measuring the efficiency in central region of the pixels:
  - The modified with gap show similar trend
  - For the modified it still depend on the pixel pitch



## APTS SF

Non-irradiated  
split: 4

$I_{reset} = 100$  pA

$I_{bias1} = 5$  μA

$I_{bias2} = 0.5$  μA

$I_{bias4} = 150$  μA

$I_{bias3} = 200$  μA

$V_{reset} = 500$  mV

$V_{pwell} = V_{sub} = -1.2$  V

$T = 20$  °C

- Modified with gap
- Modified
- Pitch = 10 μm
- Pitch = 15 μm
- Pitch = 25 μm

# Noise estimation

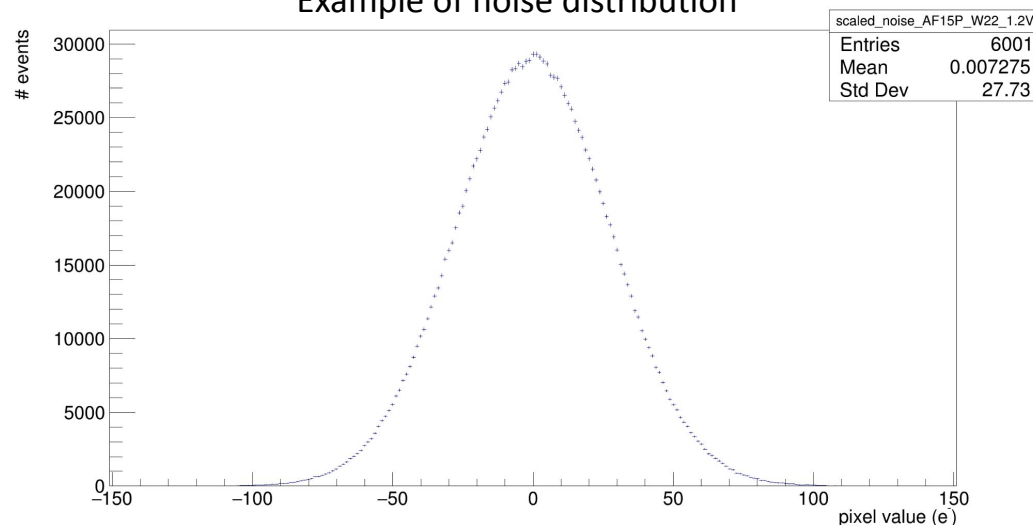
- For each event 200 frame of are recorded for the APTS ( $\approx 100$  frames before and after the trigger)
- Baseline selection: frame 96 ( $N_b$ )
- Sampling frame ( $N_s$ ): frame with the pixel with the minimum between frame 98 and 101
- For each pixel the noise is computed computed as the value in the frame:  $2N_b - N_s$

For each pixel we obtain a gaussian distribution:

- The RMS of the pixel value distributions is the noise
- Noise estimation done for all the analysed runs
- Resolutions and efficiencies plotted only for:

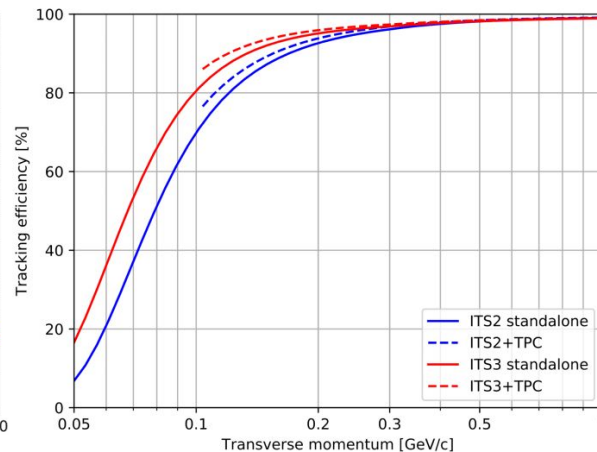
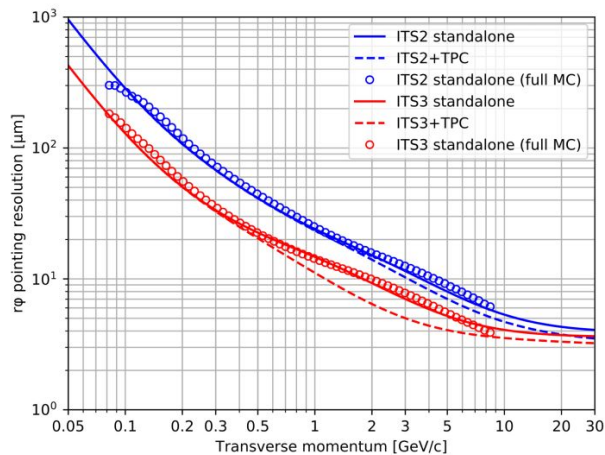
$$\text{threshold} > 3\sigma_{\text{noise}}$$

Example of noise distribution



# ALICE ITS upgrade

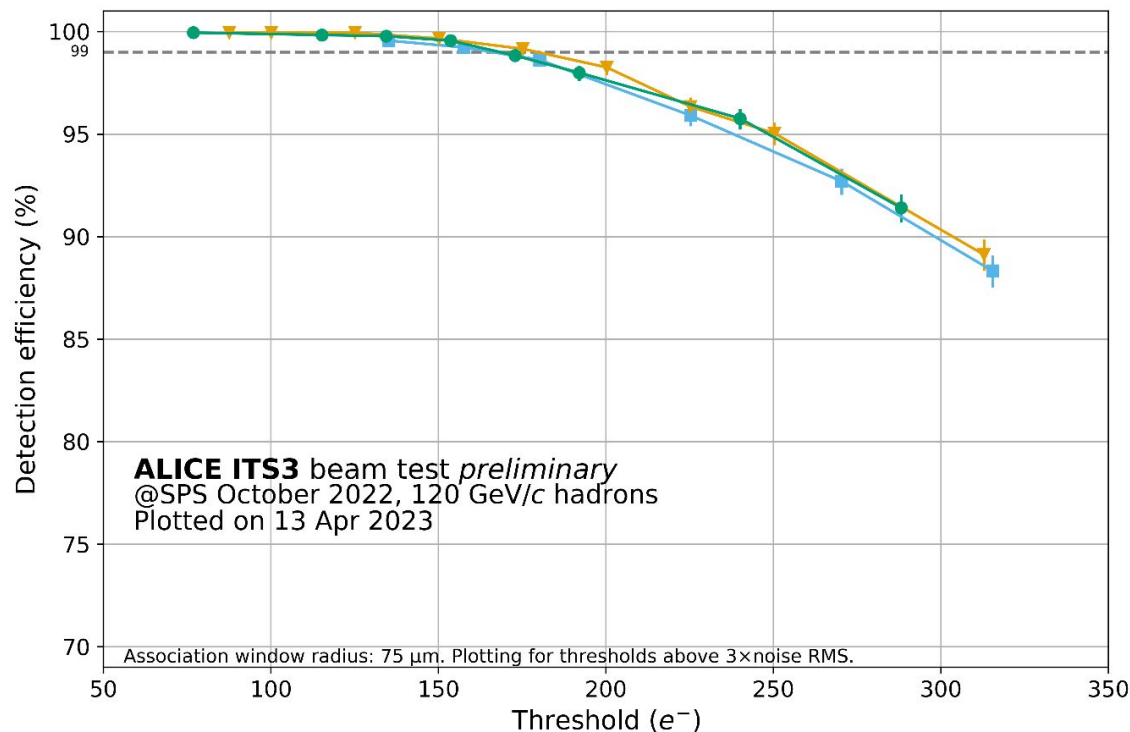
- The 3 innermost layers of the current ALICE inner tracking system (ITS2) will be replaced with the a new detector (ITS3)
- ITS3 will feature:
  - Bent detectors
  - Innermost layer closer to the interaction point: 18 mm vs 23 mm (ITS2)
  - Less material budget: 0.05%  $X_0$  vs 0.35%  $X_0$  of the current detector (ALPIDE)



# Efficiency vs threshold: mod. type bias comparison

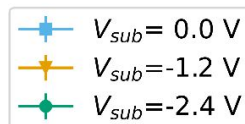
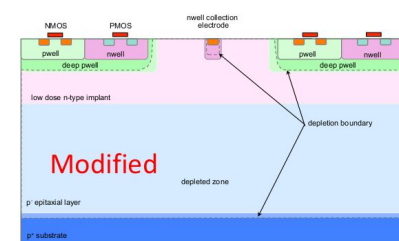


- Data plotted for threshold  $> 3\text{RMS}_{\text{noise}}$



## APTS SF

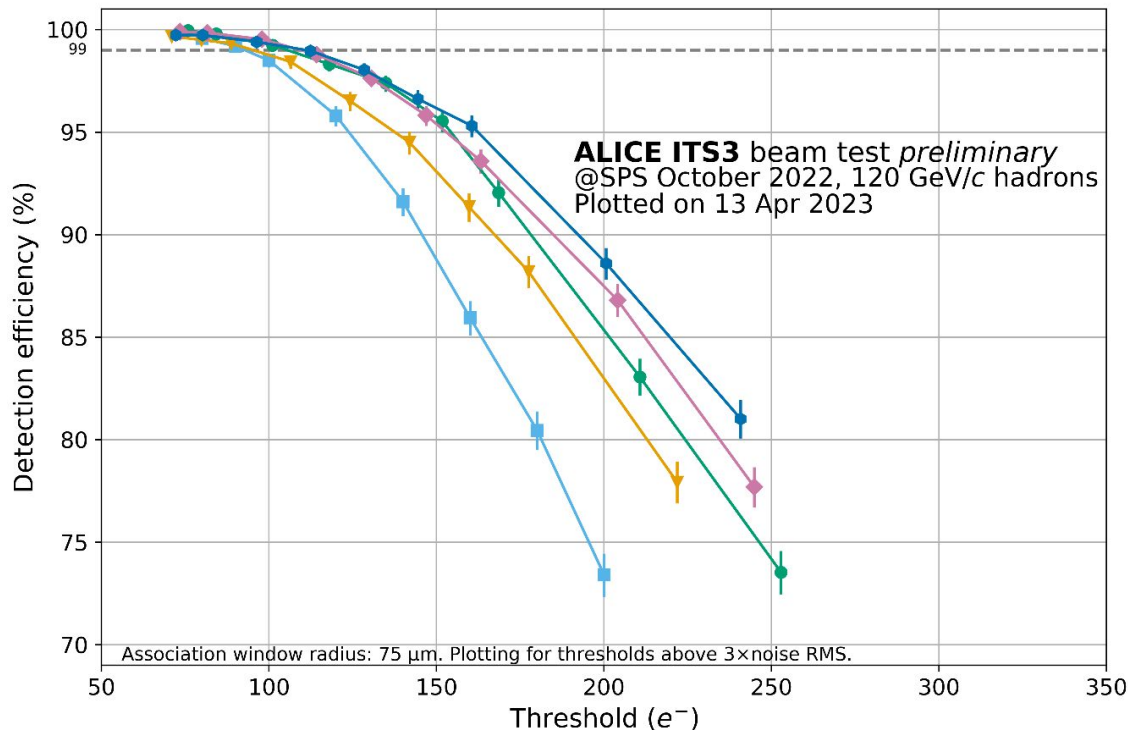
Non-irradiated  
type: modified  
pitch: 15  $\mu\text{m}$   
split: 4  
 $I_{reset} = 100\text{ pA}$   
 $I_{biasn} = 5\text{ }\mu\text{A}$   
 $I_{biasp} = 0.5\text{ }\mu\text{A}$   
 $I_{bias4} = 150\text{ }\mu\text{A}$   
 $I_{bias3} = 200\text{ }\mu\text{A}$   
 $V_{reset} = 500\text{ mV}$   
 $V_{pwell} = V_{sub}$   
 $T = 20\text{ }^\circ\text{C}$



# Efficiency vs threshold: standard type bias comparison



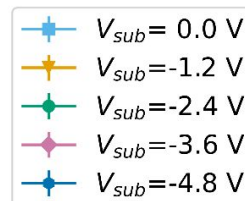
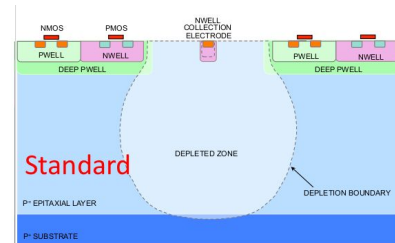
- Data plotted for threshold  $> 3\text{RMS}_{\text{noise}}$



## APTS SF

Non-irradiated  
type: standard  
pitch: 15  $\mu\text{m}$   
split: 4

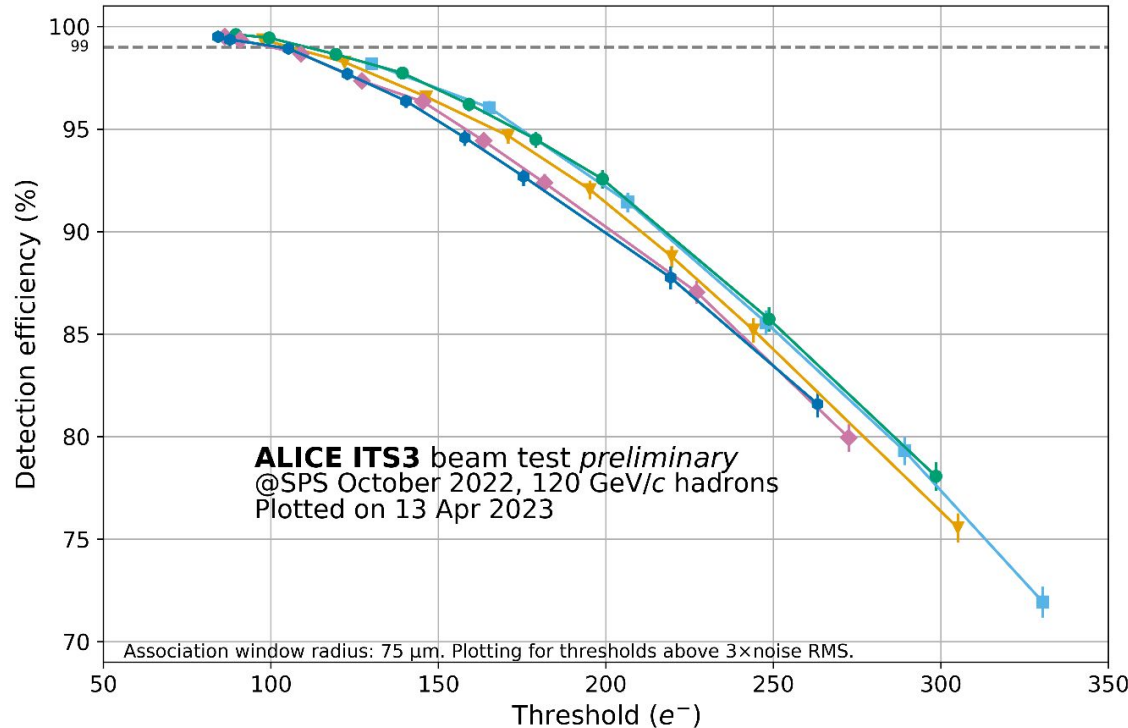
$I_{\text{reset}} = 100 \text{ pA}$   
 $I_{\text{biasn}} = 5 \text{ }\mu\text{A}$   
 $I_{\text{biasp}} = 0.5 \text{ }\mu\text{A}$   
 $I_{\text{bias4}} = 150 \text{ }\mu\text{A}$   
 $I_{\text{bias3}} = 200 \text{ }\mu\text{A}$   
 $V_{\text{reset}} = 500 \text{ mV}$   
 $V_{\text{pwell}} = V_{\text{sub}}$   
 $T = 20 \text{ }^\circ\text{C}$



# Efficiency vs threshold: Irrad. gap type bias comparison

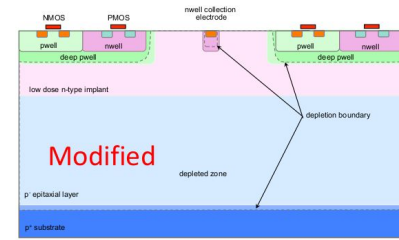


- Data plotted for threshold  $> 3\text{RMS}_{\text{noise}}$



## APTS SF

NIEL,  $10^{15}$   $1\text{MeV } n_{\text{eq}} \text{ cm}^{-2}$   
 type: modified with gap  
 pitch: 15  $\mu\text{m}$   
 split: 4  
 $I_{\text{reset}} = 250 \text{ pA}$   
 $I_{\text{biasn}} = 5 \text{ }\mu\text{A}$   
 $I_{\text{biasp}} = 0.5 \text{ }\mu\text{A}$   
 $I_{\text{bias4}} = 150 \text{ }\mu\text{A}$   
 $I_{\text{bias3}} = 200 \text{ }\mu\text{A}$   
 $V_{\text{reset}} = 500 \text{ mV}$   
 $V_{\text{pwell}} = V_{\text{sub}}$   
 $T = 15 \text{ }^\circ\text{C}$

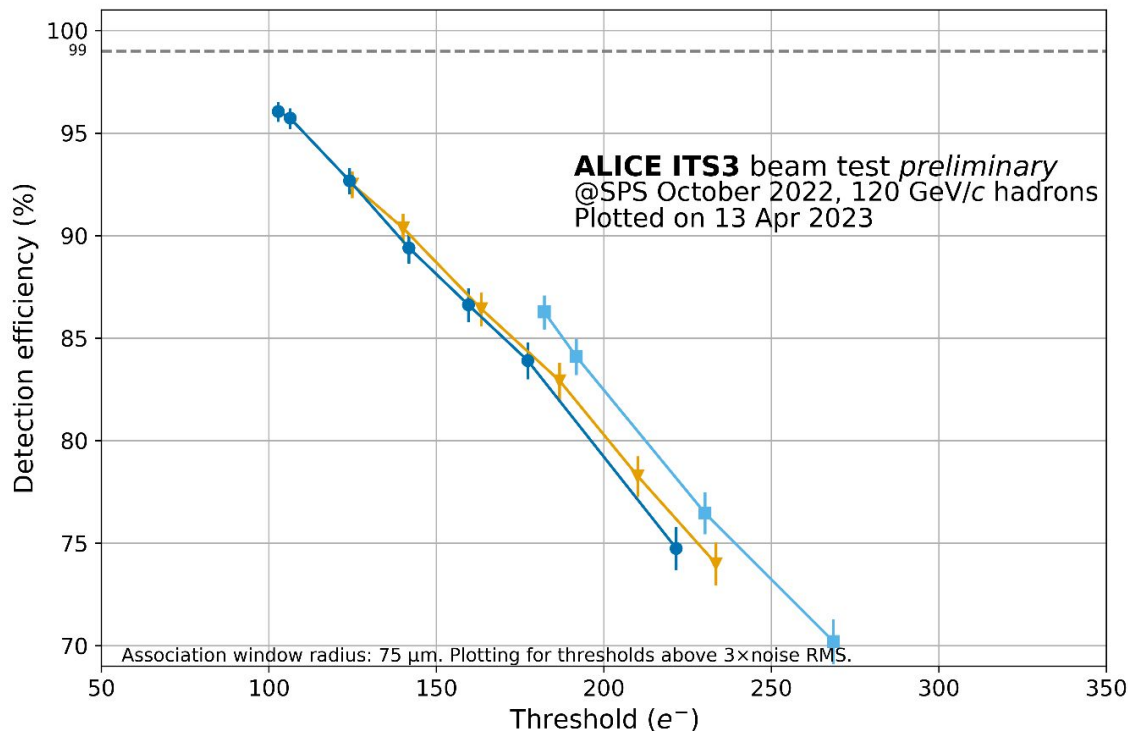


- $V_{sub} = 0.0 \text{ V}$
- $V_{sub} = -1.2 \text{ V}$
- $V_{sub} = -2.4 \text{ V}$
- $V_{sub} = -3.6 \text{ V}$
- $V_{sub} = -4.8 \text{ V}$

# Efficiency vs threshold: Irrad. gap type bias comparison



- Data plotted for threshold  $> 3\text{RMS}_{\text{noise}}$



## APTS SF

NIEL,  $2 \times 10^{15} \text{ 1MeV } n_{\text{eq}} \text{ cm}^{-2}$

type: modified with gap

pitch: 15  $\mu\text{m}$

split: 4

$I_{\text{reset}} = 250 \text{ pA}$

$I_{\text{biasn}} = 5 \text{ }\mu\text{A}$

$I_{\text{biasp}} = 0.5 \text{ }\mu\text{A}$

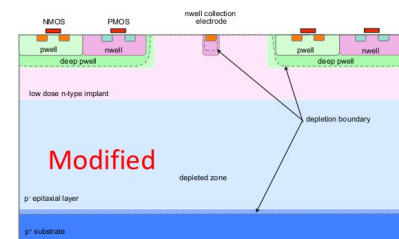
$I_{\text{bias4}} = 150 \text{ }\mu\text{A}$

$I_{\text{bias3}} = 200 \text{ }\mu\text{A}$

$V_{\text{reset}} = 500 \text{ mV}$

$V_{\text{pwell}} = V_{\text{sub}}$

$T = 15 \text{ }^\circ\text{C}$



- $V_{\text{sub}} = 0.0 \text{ V}$
- $V_{\text{sub}} = -1.2 \text{ V}$
- $V_{\text{sub}} = -4.8 \text{ V}$